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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/750,734	12/27/2000	Sanjay S. Natarajan	42390P10050	7194	
8791	7590 06/19/2002				
BLAKELY SOKOLOFF TAYLOR & ZAFMAN			EXAMINER		
	HIRE BOULEVARD, SEV ES, CA 90025	RE BOULEVARD, SEVENTH FLOOR 5, CA 90025		GURLEY, LYNNE ANN	
			ART UNIT	PAPER NUMBER	
			2812		
			DATE MAILED: 06/19/2002		

Please find below and/or attached an Office communication concerning this application or proceeding.

# Office Action Summary

Application No. **09/750,734** 

Applicant(s)

\_\_\_\_\_

Natarajan et al.

Examiner

Lynne Gurley

Art Unit 2812



	The MAILING DATE of this communication appears	on the cover sheet with the corres	pondence address			
Period for Reply						
THE	ORTENED STATUTORY PERIOD FOR REPLY IS SET MAILING DATE OF THIS COMMUNICATION. ions of time may be available under the provisions of 37 CFR 1.136 (e). In					
mailing - If the p - If NO p - Failure - Any re	ions of time may be available linear the provisions of 37 CPN 1.136 (a). In a date of this communication.  period for reply specified above is less than thirty (30) days, a reply within the period for reply is specified above, the maximum statutory period will apply a to reply within the set or extended period for reply will, by statute, cause the ply received by the Office later than three months after the mailing date of the patent term adjustment. See 37 CFR 1.704(b).	ne statutory minimum of thirty (30) days will be and will expire SIX (6) MONTHS from the mailin ne application to become ABANDONED (35 U.S	e considered timely. ng date of this communication. o.C. § 133).			
Status						
1) 💢	Responsive to communication(s) filed on Mar 18, 2	2002	·			
2a) 🗌	This action is <b>FINAL</b> . 2b)   ✓ This act	tion is non-final.				
3) 🗆	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.					
Disposi	tion of Claims					
4) 💢	Claim(s) 1-17	is/are	pending in the application.			
4	la) Of the above, claim(s) 14-17	is/ar	e withdrawn from consideration.			
5) 🗆	Claim(s)		is/are allowed.			
6) 💢	Claim(s) 1-13		is/are rejected.			
7) 🗌	Claim(s)		is/are objected to.			
8) 🗌	Claims	are subject to restric	tion and/or election requirement.			
Applica	ntion Papers					
9) 🗀	The specification is objected to by the Examiner.					
10)	The drawing(s) filed on is/are	a) accepted or b) objecte	ed to by the Examiner.			
	Applicant may not request that any objection to the d	frawing(s) be held in abeyance. Se	e 37 CFR 1.85(a).			
11)	The proposed drawing correction filed on	is: a) approved	b) $\square$ disapproved by the Examiner.			
	If approved, corrected drawings are required in reply	to this Office action.				
12)	The oath or declaration is objected to by the Exami	iner.				
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) □ All b) □ Some* c) □ None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
	<ol> <li>Copies of the certified copies of the priority depolication from the International Bure the attached detailed Office action for a list of the</li> </ol>	au (PCT Rule 17.2(a)).	this National Stage			
	Acknowledgement is made of a claim for domestic	•	e)			
_	The translation of the foreign language provisiona	•	<b>5</b> 7.			
15)	Acknowledgement is made of a claim for domestic		o and/or 121.			
Attachment(s)						
	otice of References Cited (PTO-892)	4) Interview Summary (PTO-413) Paper	No(s)			
2) 🔲 No	otice of Draftsperson's Patent Drawing Review (PTO-948)	5) Notice of Informal Patent Application	(PTO-152)			
3) 🔲 tnf	formation Disclosure Statement(s) (PTO-1449) Paper No(s).	6) Other:				

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#### **DETAILED ACTION**

#### Election/Restriction

1. Applicant's election without traverse of claims 1-13 in Paper No. 5 is acknowledged.

# Specification

2. The specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

## Claim Rejections - 35 USC § 112

3. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

- 4. Claim 7 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.
- 5. Claim 7 recites the limitation "the etch stop layer" in line 4. There is insufficient antecedent basis for this limitation in the claim.

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### Claim Rejections - 35 USC § 102

6. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 7. Claims 1-5 and 7-11 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Jang et al. (US 5,840,624, dated 11/24/1998).
- a.Jang shows the method as claimed in figures 5-8 and corresponding text, with dielectric layers 8, 19 and 23 and etch stop layer 20.

### Claim Rejections - 35 USC § 103

- b. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- c. The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
  - 1. Determining the scope and contents of the prior art.
  - 2. Ascertaining the differences between the prior art and the claims at issue.

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3. Resolving the level of ordinary skill in the pertinent art.

 Considering objective evidence present in the application indicating obviousness or nonobviousness.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103© and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

d. Claims 6 and 12-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Jang et al. (US 5,840,624, dated 11/24/98) in view of Andideh et al. (US 6,362,091, dated 3/26/02, filed 3/14/00).

Jang shows the method substantially as claimed and as described int he preceding paragraphs.

Jang lacks anticipation only in not teaching that there are at least 6 alternating silicon dioxide layers.

Andideh teaches multiple layers of this quantity for an improved contact formation with lower dielectric constant and greater etch control.

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It would have been obvious to one of ordinary skill in the art to have used the multiple dielectric layers taught in the method of Andideh to form the structure shown in Jang with the

motivation that Andideh's structure improves etch control and contact resistance and reliability.

Prior Art Of Record

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. See the PTO Form 892 for similar structures of multiple silicon dioxide formation.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lynne A. Gurley whose telephone number is 305-3474. The examiner can normally be reached on Monday-Friday from 7:30 AM to 4:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John F. Niebling, can be reached on (703) 308-3325. The fax phone number for the organization where this application or proceeding is assigned is 308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 308-0956.

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June 17, 2002